

**EPFL STI IMT-NE PV-LAB**

**Seminar**

**Wednesday 19<sup>th</sup> September 2012**

**MT 1 11.00 - ≈ 12.00**

Rue A.-L. Breguet 2, CH-2000 Neuchâtel

**Research and development of microcrystalline silicon thin film solar cells at Nankai University**

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**Main contents about the presentation**

- 1. Brief introduction about Nankai University, China**
- 2. Brief introduction about Institute of Photo-electronic Thin Film Devices and Technology---especially silicon based thin film solar cells group**
- 3. Basic research about microcrystalline silicon solar cells in our group**
  - Transparent conductive oxide---deposited by sputtering and MOCVD technique
  - “New” back reflector-----SiOx/metals
  - High deposition rate microcrystalline silicon solar cells
  - High pressure technique for p layer
  - Single chamber deposition microcrystalline silicon solar cells
  - Tandem solar cells